



Docket No: TSMC2003-0017/24061.506
Customer Number: 42717

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:
Lin et al.

Serial No.: 10/718,876

Filed: 11/21/2003

For: Phosphoric Acid Free Process for
Polysilicon Gate Definition

§
§
§
§
§
§
§

Attorney Docket: TSMC2003-0017/24061.506

Confirmation Number: 1467

Art Unit: 2813

Examiner: Nguyen, Thanh T.

Notice of Allowance: 09/20/2004

Commissioner for Patents
PO Box 1450
Alexandria, VA 22313-1450
MAIL STOP ISSUE FEE

TRANSMITTAL

Dear Sir:

In response to the Notice of Allowance and Issue Fee Due mailed on September 20, 2004, enclosed are the following:

1. Part B - Issue Fee Transmittal (in duplicate);
2. Check in the amount of \$1670.00;
3. Revocation and New Power of Attorney (2 pages);
4. Fee Address Indication Form; and
5. Return postcard.

The Commissioner is hereby authorized to charge Deposit Account No. 08-1394 for any deficiencies in the enclosed fees. This sheet submitted in duplicate.

Respectfully submitted,

David M. O'Dell
Registration No. 42,044

Date: 11-29-04
HAYNES AND BOONE, LLP
901 Main Street, Suite 3100
Dallas, Texas 75202-3789
Telephone: 972-739-8635
Facsimile: 214-200-0853
R92166.1

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an envelope addressed to: Commissioner for Patents
PO Box 1450, Alexandria, VA 22313-1450

on

11-30-04

Bonnie E. Boyle